

Title (en)

Rhodium bath and process for rhodium deposition

Title (de)

Rhodiumbad und Verfahren zum Abscheiden von Rhodium

Title (fr)

Bain de rhodium et procédé pour le dépôt du rhodium

Publication

EP 1035229 B1 20060913 (DE)

Application

EP 00103134 A 20000216

Priority

DE 19909678 A 19990305

Abstract (en)

[origin: DE19909678C1] Rhodium plating bath comprises water and a readily water-soluble rhodium compound selected from ammonium rhodium(III) di(pyridine-2,6-dicarboxylate), rhodium amine complexes, rhodium acetate and rhodium chloride triethylenetetramine or diethylenetriamine complexes. Rhodium plating bath comprises water and a readily water-soluble rhodium compound selected from ammonium rhodium(III) di(pyridine-2,6-dicarboxylate), rhodium amine complexes of formula (I), rhodium acetate and rhodium chloride triethylenetetramine or diethylenetriamine complexes: $\text{RuCl}_x(\text{NH}_3)_{6-x}$ (I) $x = 0-3$.

IPC 8 full level

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